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分機：

參考資料目錄:

A. Referred International Journal Papers (國際期刊論文)

B. International Conference Papers (國際研討會論文)

C. 專利發明

D. 國科會計畫

E. 其他政府部門計畫

F. 產學計畫

G. 指導學生獲獎

H. 荣譽與獎勵

A. Referred International Journal Papers (國際期刊論文)

- A1. C. K. Wang*, Y. Z. Chiou, and Y. L. Huang, “GaAs-Based p-i-n Narrow Bandpass 850 nm IR Photodetector With a p-AlGaAs Filter Layer”, *IEEE Sens. J.*, Vol. 21, No. 21, pp. 23995-23999, November 2021.
- A2. J. S. Jheng, C. K. Wang*, Y. Z. Chiou, S. P. Chang, and S. J. Chang, “Voltage-Tunable UVC–UVB Dual-Band Metal–Semiconductor–Metal Photodetector Based on Ga₂O₃/MgZnO Heterostructure by RF Sputtering”, *Coatings*, Vol. 10, No. 10, p. 994, October 2020.
- A3. J. S. Jheng, C. K. Wang*, Y. Z. Chiou, S. P. Chang, and S. J. Chang, “MgZnO MSM UV Photodetector with Different Annealing Temperatures by RF Magnetron Sputtering”, *ECS J. Solid State Sci. Technol.*, Vol. 9, No. 5, p. 055015, June 2020.

- A4. J. S. Jheng, C. K. Wang*, Y. Z. Chiou, S. P. Chang, and S. J. Chang, “MgZnO/SiO₂/ZnO metal–semiconductor–metal dual-band UVA and UVB photodetector with different MgZnO thicknesses by RF magnetron sputter”, *Jpn. J. Appl. Phys.*, Vol. 59, No. SD, p. SDDF04, March 2020.
- A5. C. K. Wang*, Y. Z. Chiou, and H. J. Chang, “Investigating the Efficiency Droop of Nitride-Based Blue LEDs with Different Quantum Barrier Growth Rates”, *Crystals*, Vol. 9, No. 12, p. 677, December 2019.
- A6. J. S. Jheng, C. K. Wang*, Y. Z. Chiou, S. P. Chang, and S. J. Chang, “GaN-Based Blue Light-Emitting Diodes With an Electron Transmission Layer”, *ECS J. Solid State Sci. Technol.*, Vol. 6, No. 10, pp. R154-R157, November 2017.
- A7. C. K. Wang*, Y. W. Wang, Y. Z. Chiou, S. H. Chang, J. S. Jheng, S. P. Chang, and S. J. Chang, “Suppression of Electron Overflow in 370-nm InGaN/AlGaN Ultraviolet Light Emitting Diodes with Different Insertion Layer Thicknesses”, *J. Cryst. Growth*, Vol. 468, pp. 585-589, June 2017.
- A8. C. K. Wang*, K. C. Hung, Y. Z. Chiou, J. S. Jheng, S. P. Chang, and S. J. Chang, “Suppressing Efficiency Droop Using Graded AlGaN/InGaN Superlattice Electron Blocking Layer for InGaN-based Light-Emitting Diodes”, *J. Cryst. Growth*, Vol. 468, pp. 562-566, June 2017.
- A9. S. W. Wang, C. K. Wang*, S. J. Chang, Y. Z. Chiou, K. W. Chiang, J. S. Jheng, and S. P. Chang, “Investigation the effect of nitride-based LEDs fabricated using hole injection layer at different growth temperatures”, *Jpn. J. Appl. Phys.*, Vol. 55, No. 5S, pp. 05FJ14-1~4, May 2016.
- A10. C. K. Wang*, Y. Z. Chiou, P. K. Lin, J. S. Jheng, S. P. Chang, and S. J. Chang, “Performance Enhancement of Blue InGaN Light-Emitting Diodes with P-GaN/InGaN SPS Last Barrier and P-AlGaN/GaN SPS EBL”, *ECS J. Solid State Sci. Technol.*, Vol. 5, No. 6, pp. Q179-Q182, April 2016.
- A11. C. K. Wang*, Y. Z. Chiou, and S. B. Chuang, “Enhancement in Output Power of Blue Nitride-Based Light-Emitting Diodes With an Electron Retarded Layer”, *IEEE/OSA J. Disp. Technol.*, Vol. 11, No. 12, pp. 1005-1009, December 2015.
- A12. C. K. Wang*, Y. Z. Chiou, S. J. Chang, W. C. Lai, S. P. Chang, C. H. Yen, and C. C. Hung, “GaN MSM UV Photodetector With Sputtered AlN Nucleation Layer”, *IEEE Sens. J.*, Vol. 15, No. 9, pp. 4743-4748, September 2015.
- A13. Y. W. Lin, C. K. Wang*, Y. Z. Chiou, H. M. Chang, and S. J. Chang, “Investigation of optical and electrical properties of GaN-based blue light-emitting diodes with various quantum well thicknesses”, *J. Photonics Energy*, Vol. 5, No. 1, p. 057612-1~057612-8, July 2015.
- A14. C. K. Wang*, Y. Z. Chiou, T. H. Chiang, and T. K. Lin, “Investigating the Effect of Piezoelectric Polarization on GaN-Based LEDs with Different Prestrain Layer by Temperature-Dependent Electroluminescence”, *Int. J. Photoenergy*, Vol. 2015, Article ID 135321, June 2015.
- A15. C. K. Wang*, Y. Z. Chiou, S. J. Chang, C. Y. Chang, T. H. Chiang, T. K. Lin, and X. Q. Li, “On the effect of quantum barrier thickness in the active region of nitride-based light emitting diodes”, *Solid-State Electron.*, Vol. 99, pp. 11-15, September 2014.
- A16. C. K. Wang*, Y. Z. Chiou, C. C. Hsiang, D. H. Lee, W. Y. Yan, W. S. Chen, C. M. Cheng, K. H. Chen, J. J. Tang, and J. Lee, “Enhancement of optical performance of near-UV nitride-based light emitting diodes with different aluminum composition barrier structure”, *Phys. Status Solidi A-Appl. Mat.*, Vol. 211, No. 8, pp. 1769-1772, August 2014.
- A17. W. C. Lai, C. H. Yen, Y. Y. Yang, C. K. Wang, and S. J. Chang, “GaN-Based Ultraviolet Light Emitting Diodes With Ex Situ Sputtered AlN Nucleation Layer”, *IEEE/OSA J. Disp. Technol.*, Vol. 9, No. 11, pp. 895-899, November 2013.
- A18. C. K. Wang*, Y. Z. Chiou, and D. J. Sun, “The Hot-Cold Effect on Optical Properties for Nitride-Based Green LEDs by Ammonia Source Preflow”, *ECS J. Solid State Sci. Technol.*, Vol. 2, No. 7, pp. Q104-107, May 2013.

- A19. C. K. Wang*, T. H. Chiang, K. Y. Chen, Y. Z. Chiou, T. K. Lin, S. P. Chang, and S. J. Chang, "Investigating the Effect of Piezoelectric Polarization on GaN-Based LEDs With Different Quantum Barrier Thickness", *IEEE/OSA J. Disp. Technol.*, Vol. 9, No. 4, pp. 207-212, April 2013.
- A20. C. K. Wang*, Y. Z. Chiou, D. J. Sun, and T. H. Chiang, "Low Dislocation Densities of Nitride-Based Light-Emitting Diodes with a Preflow of NH₃ Source before Growth of AlN Buffer Layer", *Jpn. J. Appl. Phys.*, Vol. 52, No. 1, pp. 01AG07-1-4, January 2013.
- A21. C. K. Wang*, T. H. Chiang, Y. Z. Chiou, and S. P. Chang, "Reducing the Current Crowding Effect on Nitride-Based Light-Emitting Diodes Using Modulated P-Extension Electrode Thickness", *Jpn. J. Appl. Phys.*, Vol. 52, No. 1, pp. 01AG05-1-4, January 2013.
- A22. T. H. Chiang, C. K. Wang*, S. J. Chang, Y. Z. Chiou, T. K. Ko, T. K. Lin and S. P. Chang, "Effect of Varied Undoped GaN Thickness on ESD and Optical Properties of GaN-Based LEDs", *IEEE Photonics Technol. Lett.*, Vol. 24, No. 10, pp. 800-802, May 2012.
- A23. C. H. Yen, W. C. Lai, Y. Y. Yang, C. K. Wang, T. K. Ko, S. J. Hon, and S. J. Chang, "GaN-Based Light-Emitting Diode With Sputtered AlN Nucleation Layer", *IEEE Photonics Technol. Lett.*, Vol. 24, No. 4, pp. 294-296, February 2012.
- A24. C. D. Yerino, Y. Zhang, B. Leung, M. L. Lee, T. C. Hsu, C. K. Wang, W. C. Peng, and J. Han, "Shape transformation of nanoporous GaN by annealing: From buried cavities to nanomembranes", *Appl. Phys. Lett.*, Vol. 98, No. 25, pp. 251910 1-3, June 2011.
- A25. T. H. Chiang, Y. Z. Chiou, S. J. Chang, C. K. Wang, T. K. Ko, T. K. Lin, C. J. Chiu, and S. P. Chang, "Improved Optical and ESD Characteristics for GaN-Based LEDs With an n⁻-GaN Layer", *IEEE Trans. Device Mater. Reliab.*, Vol. 11, No. 1, pp. 76-80, March 2011.
- A26. Y. Z. Chiou, Y. C. Lin, and C. K. Wang, "AlGaN Photodetector Prepared on Si Substrates", *IEEE Electron Device Lett.*, Vol. 28, No. 4, pp. 264-266, April 2007.
- A27. C. H. Liu, K. T. Lam, S. J. Chang, and C. K. Wang, "Flicker Noise of AlGaN/GaN Metal-Oxide-Semiconductor Heterostructure Field-Effect Transistor with a Photo-CVD SiO₂ Layer", *J. Electrochem. Soc.*, Vol. 154, No. 2, pp. H119-H123, February 2007.
- A28. T. K. Ko, S. C. Shei, S. J. Chang, Y. K. Su, Y. Z. Chiou, Y. C. Lin, C. S. Chang, W. S. Chen, C. K. Wang, J. K. Sheu, and W. C. Lai, "Flip-Chip p(GaN)-i(GaN)-n(AlGaN) Narrowband UV-A Photosensors", *IEEE Sens. J.*, Vol. 6, No. 4, pp. 964-969, August 2006.
- A29. S. J. Chang, T. K. Lin, Y. K. Su, Y. Z. Chiou, C. K. Wang, S. P. Chang, C. M. Chang, J. J. Tang, and B. R. Huang, "ITO/Homoepitaxial ZnSe/ITO MSM Sensors With Thermal Annealing", *IEEE Sens. J.*, Vol. 6, No. 4, pp. 945-949, August 2006.
- A30. T. K. Lin, S. J. Chang, Y. Z. Chiou, C. K. Wang, S. P. Chang, K. T. Lam, Y. S. Sun, and B. R. Huang, "Homoepitaxial ZnSe MIS photodetectors with SiO₂ and BST insulator layers", *Solid-State Electron.*, Vol. 50, No. 5, pp. 750-753, May 2006.
- A31. Y. Z. Chiou, Y. K. Su, J. Gong, S. J. Chang, and C. K. Wang, "Noise Analysis of Nitride-Based Metal-Oxide-Semiconductor Heterostructure Field Effect Transistors with Photo-Chemical Vapor Deposition SiO₂ Gate Oxide in the Linear and Saturation Regions", *Jpn. J. Appl. Phys.*, Vol. 45, No. 4B, pp. 3405-3409, April 2006.
- A32. C. H. Liu, T. K. Lin, S. J. Chang, Y. K. Su, Y. Z. Chiou, C. K. Wang, S. P. Chang, J. J. Tang, and B. R. Huang, "Photo-assisted thermally oxidized GaAs insulator layers deposited by photo-CVD", *Surf. Coat. Technol.*, Vol. 200, No. 10, pp. 3250-3253, February 2006.

- A33.S. J. Chang, T. K. Lin, Y. K. Su, Y. Z. Chiou, C. K. Wang, S. P. Chang, C. M. Chang, J. J. Tang, and B. R. Huang, “Homoepitaxial ZnSe MSM photodetectors with various transparent electrodes”, *Mater. Sci. Eng. B-Solid State Mater. Adv. Technol.*, Vol. 127, No. 2-3, pp. 164-168, February 2006.
- A34.C. K. Wang, S. J. Chang, Y. K. Su, Y. Z. Chiou, T. K. Lin, C. C. Wong, H. L. Liu, S. P. Chang, and J. J. Tang, “Room temperature photo-CVD SiO₂ layers on AlGaN and AlGaN/GaN MOS-HFETs”, *Phys. Status Solidi A-Appl. Mat.*, Vol. 203, No. 2, pp. 404-409, February 2006.
- A35.C. K. Wang, S. J. Chang, Y. K. Su, Y. Z. Chiou, S. C. Chen, C. S. Chang, T. K. Lin, H. L. Liu, and J. J. Tang, “GaN MSM UV Photodetectors With Titanium Tungsten Transparent Electrodes”, *IEEE Trans. Electron Devices*, Vol. 53, No. 1, pp. 38-42, January 2006.
- A36.C. K. Wang, T. K. Ko, C. S. Chang, S. J. Chang, Y. K. Su, T. C. Wen, C. H. Kuo, and Y. Z. Chiou, “The Thickness Effect of p-AlGaN Blocking Layer in UV-A Bandpass Photodetectors”, *IEEE Photonics Technol. Lett.*, Vol. 17, No. 10, pp. 2161-2163, October 2005.
- A37.S. J. Chang, C. K. Wang, Y. K. Su, C. S. Chang, T. K. Lin, T. K. Ko, and H. L. Liu, “GaN MIS Capacitors with Photo-CVD SiN_xO_y Insulating Layers”, *J. Electrochem. Soc.*, Vol. 152, No. 6, pp. G423-G426, June 2005.
- A38.C. K. Wang, S. J. Chang, Y. K. Su, Y. Z. Chiou, C. S. Chang, T. K. Lin, H. L. Liu, and J. J. Tang, “High detectivity GaN metal-semiconductor-metal UV photodetectors with transparent tungsten electrodes”, *Semicond. Sci. Technol.*, Vol. 20, No. 6, pp. 485-489, June 2005.
- A39.C. K. Wang, R. W. Chuang, S. J. Chang, Y. K. Su, S. C. Wei, T. K. Lin, T. K. Ko, Y. Z. Chiou, and J. J. Tang, “High temperature and high frequency characteristics of AlGaN/GaN MOS-HFETs with photochemical vapor deposition SiO₂ layer”, *Mater. Sci. Eng. B-Solid State Mater. Adv. Technol.*, Vol. 119, No. 1, pp. 25-28, May 2005.
- A40.T. K. Lin, S. J. Chang, Y. K. Su, Y. Z. Chiou, C. K. Wang, S. P. Chang, C. M. Chang, J. J. Tang, and B. R. Huang, “ZnSe MSM photodetectors prepared on GaAs and ZnSe substrates”, *Mater. Sci. Eng. B-Solid State Mater. Adv. Technol.*, Vol. 119, No. 2, pp. 202-205, May 2005.
- A41.C. K. Wang, S. J. Chang, Y. K. Su, Y. Z. Chiou, C. H. Kuo, C. S. Chang, T. K. Lin, T. K. Ko, and J. J. Tang, “High Temperature Performance and Low Frequency Noise Characteristics of AlGaN/GaN/AlGaN Double Heterostructure Metal-Oxide-Semiconductor Heterostructure Field-Effect-Transistors with Photochemical Vapor Deposition SiO₂ Layer”, *Jpn. J. Appl. Phys.*, Vol. 44, No. 4B, pp. 2458-2461, April 2005.
- A42.T. K. Lin, S. J. Chang, Y. K. Su, Y. Z. Chiou, C. K. Wang, C. M. Chang, and B. R. Huang, “ZnSe Homoepitaxial MSM Photodetectors With Transparent ITO Contact Electrodes”, *IEEE Trans. Electron Devices*, Vol. 52, No. 1, pp. 121-123, January 2005.
- A43.T. M. Kuan, S. J. Chang, Y. K. Su, J. C. Lin, S. C. Wei, C. K. Wang, C. I. Huang, W. H. Lan, J. A. Bardwell, H. Tang, W. J. Lin, and Y. T. Cherng, “High-performance GaN/InGaN heterostructure FETs on Mg-doped GaN current blocking layers”, *J. Cryst. Growth*, Vol. 272, No. 1-4, pp. 300-304, December 2004.
- A44.C. K. Wang, S. J. Chang, Y. K. Su, C. S. Chang, Y. Z. Chiou, C. H. Kuo, T. K. Lin, T. K. Ko, and J. J. Tang, “GaN MSM photodetectors with TiW transparent electrodes”, *Mater. Sci. Eng. B-Solid State Mater. Adv. Technol.*, Vol. 112, No. 1, pp. 25-29, September 2004.
- A45.C. H. Liu, C. K. Wang, S. J. Chang, and Y. K. Su, “High transconductance nitride MOSHFETs”, *Mater. Sci. Eng. B-Solid State Mater. Adv. Technol.*, Vol. 110, No. 1, pp. 32-33, June 2004.

- A46.L. W. Ji, Y. K. Su, S. J. Chang, S. C. Hung, C. K. Wang, T. H. Fang, T. Y. Tsai, R. Chuang, W. Su, and J. C. Zhong, “InGaN Metal–Semiconductor–Metal Photodiodes with Nanostructures”, *Jpn. J. Appl. Phys.*, Vol. 43, No. 2, pp. 518-521, February 2004.
- A47.C. S. Chang, S. J. Chang, Y. K. Su, W. C. Lai, C. H. Kuo, C. K. Wang, Y. C. Lin, Y. P. Hsu, S. C. Shei, H. M. Lo, J. C. Ke, and J. K. Sheu, “High brightness InGaN/GaN LEDs with indium-tin-oxide as p-electrode”, *Phys. Status Solidi C*, Vol. 0, No. 7, pp. 2227-2231, December 2003.
- A48.C. K. Wang, S. J. Chang, Y. K. Su, Y. Z. Chiou , T. K. Lin and B. R. Huang, “Low interface state density AlGaN/GaN MOSHFETs with photochemical vapor deposition SiO₂ layers”, *Phys. Status Solidi C*, Vol. 0, No. 7, pp. 2355-2359, December 2003.
- A49.C. K. Wang, T. K. Lin, Y. Z. Chiou, S. J. Chang, Y. K. Su, C. H. Kuo, and T. K. Ko, “High transconductance AlGaN/GaN MOSHFETs with photo-CVD gate oxide”, *Semicond. Sci. Technol.*, Vol. 18, No. 12, pp. 1033-1036, December 2003.
- A50.C. H. Kuo, S. J. Chang, Y. K. Su, C. K. Wang, L. W. Wu J. K. Sheu, T. C. Wen, W. C. Lai, J. M. Tsai and C. C. Lin, “Nitride-based blue LEDs with GaN/SiN double buffer layers”, *Solid-State Electron.*, Vol. 47, No. 11, pp. 2019-2022, November 2003.
- A51.L. W. Ji, Y. K. Su, S. J. Chang, S. H. Liu, C. K. Wang, S. T. Tsai, T. H. Fang, L. W. Wu, and Q. K. Xue, “InGaN quantum dot photodetectors”, *Solid-State Electron.*, Vol. 47, No. 10, pp. 1753-1756, October 2003.
- A52.Y. Z. Chiou, S. J. Chang, Y. K. Su, C. K. Wang, T. K. Lin and B. R. Huang, “Photo-CVD SiO₂ Layers on AlGaN and AlGaN-GaN MOSHFET”, *IEEE Trans. Electron Devices*, Vol. 50, No. 8, pp. 1748-1752, August 2003.
- A53.C. K. Wang, Y. Z. Chiou, S. J. Chang, Y. K. Su, B. R. Huang, T. K. Lin and S. C. Chen, “AlGaN/GaN Metal-Oxide Semiconductor Heterostructure Field-Effect Transistor with Photo-Chemical-Vapor Deposition SiO₂ Gate Oxide”, *J. Electron. Mater.*, Vol. 32, No. 5, pp. 407-410, May 2003.

B. International Conference Papers (國際研討會論文)

- B1. Y. K. Peng, C. K. Wang, Y. Z. Chiou, and J. H. Huan, “The Time Response of Vertical β-Ga₂O₃ Deep Ultraviolet Photodetectors on p-Si Substrate”, *2024 International Electron Devices and Materials Symposium (2024 IEDMS), 2024 Taichung Taiwan*.
- B2. S. H. Wu, C. K. Wang, Y. Z. Chiou, and J. H. Huang, “β-Ga₂O₃/Si p-n Heterojunction DUV Photodetectors on p-type Si Substrates by RF Magnetron Sputtering”, *2023 Optics & Photonics Taiwan, International Conference (OPTIC), 2023 Tainan Taiwan*.
- B3. Y. K. Peng, C. K. Wang, Y. Z. Chiou, and H. D. Liou, “MSM Ga₂O₃ Deep Ultraviolet Photodetectors on Sapphire Substrates with Different Annealing Temperatures by RF Sputtering”, *2023 International Symposium on Novel and Sustainable Technology (ISNST), 2023 Tainan Taiwan*.
- B4. R. Q. Jiang, C. K. Wang, Y. Z. Chiou, and Y. D. Tsai, “Improving the Schottky Barrier Height of Vertical β-Ga₂O₃ Schottky Diodes with Ni/Au Contact by Annealing at Different Temperatures”, *2023 International Electron Devices and Materials Symposium (2023 IEDMS), 2023 Kaohsiung Taiwan*.
- B5. Y. D. Tsai, C. K. Wang, Y. Z. Chiou, and L. R. Huang, “The Time Response of MgZnO MSM UV Photodetectors by RF Sputter on Different Substrates”, *2022 Optics & Photonics Taiwan, International Conference (OPTIC), 2022 Taoyuan Taiwan*.
- B6. J. H. Huang, C. K. Wang, Y. Z. Chiou, and W. F. Wang, “Study on β-Ga₂O₃ MSM Deep UV Photodetectors Deposited on

Different Substrates by RF Magnetron Sputtering”, *2022 International Symposium on Novel and Sustainable Technology (ISNST), 2022 Tainan Taiwan.*

- B7. H. T. Liu, C. K. Wang, Y. Z. Chiou, and J. J. Liu, “Investigations on the Temperature-Dependent Photo Response of GaAs-Based p-i-n 850 nm Band-Pass Near-Infrared Photodetectors”, *2022 International Electron Devices and Materials Symposium (2022 IEDMS), 2022 Nantou Taiwan.*
- B8. W. F. Wang, C. K. Wang, Y. Z. Chiou, J. S. Jheng, and Z. Y. Huang, “The Study of Ga_2O_3 Metal-Semiconductor-Metal Photodetector by RF Magnetron Sputter and Hydride Vapor Phase Epitaxy”, *2021 Optics & Photonics Taiwan, International Conference (OPTIC), 2021 Kaohsiung Taiwan.*
- B9. L. H. Chen, C. K. Wang, Y. Z. Chiou, J. S. Jheng, and Y. X. Xu, “The Study of Ga_2O_3 Metal-Semiconductor-Metal and Metal-Oxide-Semiconductor Photodetectors”, *2021 International Symposium on Novel and Sustainable Technology (ISNST), 2021 Tainan Taiwan.*
- B10. L. R. Huang, C. K. Wang, Y. Z. Chiou, Z. H. Lin, and J. S. Jheng, “The investigation of low-frequency noise in Ga_2O_3 deep ultraviolet MSM photodetector with different annealed temperatures”, *2021 International Electron Devices and Materials Symposium (2021 IEDMS), 2021 Tainan Taiwan.*
- B11. J. J. Liu, J. S. Jheng, Y. Z. Chiou, and C. K. Wang, “The GaAs-based p-i-n photodetector using in glucose detection”, *2021 IEEE International Conference on Consumer Electronics-Taiwan (ICCE-TW), 2021 Penghu Taiwan.*
- B12. Z. H. Lin, C. K. Wang, Y. Z. Chiou, and J. S. Jheng, “Investigation of $\text{MgZnO}/\text{Ga}_2\text{O}_3$ Dual-Band Ultraviolet Photodetectors with Different Thicknesses of SiO_2 Inserting Layer by RF Magnetron Sputter”, *2020 Optics & Photonics Taiwan, International Conference (OPTIC), 2020 Taipei Taiwan.*
- B13. C. W. Huang, C. K. Wang, Y. Z. Chiou, and J. S. Jheng, “The Study of InGaAs-Based p-i-n Band-Pass Near-IR Photodetector Grown by Metal-Organic Chemical Vapor Deposition”, *2020 Optics & Photonics Taiwan, International Conference (OPTIC), 2020 Taipei Taiwan.*
- B14. Z. Y. Huang, C. K. Wang, and Y. Z. Chiou, “The Study of $\text{Ga}_2\text{O}_3/\text{MgZnO}$ Dual-Band Ultraviolet Photodetectors”, *2020 International Symposium on Novel and Sustainable Technology (ISNST), 2020 Tainan Taiwan.*
- B15. H. C. Fu, C. K. Wang, and Y. Z. Chiou, “The Study of InGaN-Based P-I-N Band-Pass Photodetector”, *2019 International Symposium on Novel and Sustainable Technology (ISNST), 2019 Tainan Taiwan.* (ISBN: 978-986-5627-65-2)
- B16. Y. L. Huang, C. K. Wang, and Y. Z. Chiou, “GaAs-Based Infrared Photodetectors with Different Filters”, *2019 International Symposium on Novel and Sustainable Technology (ISNST), 2019 Tainan Taiwan.* (ISBN: 978-986-5627-65-2)
- B17. Y. X. Xu, C. K. Wang, and Y. Z. Chiou, “GaAs-Based p-i-n Band-Pass Near-Infrared Photodetector Grown by Metal-Organic Chemical Vapor Deposition”, *2019 The 18th International Symposium on Advanced Technology (ISAT-18), 2019 Tainan Taiwan.* (ISBN: 978-986-5627-63-8)
- B18. H. C. Fu, C. K. Wang, Y. Z. Chiou, W. H. Liao, J. S. Jheng, S. P. Chang, and S. J. Chang, “The Study of $\text{ZnO}/\text{Mg}_x\text{Zn}_{1-x}\text{O}$ Dual-Band Metal-Semiconductor-Metal Photodetector with Different Thicknesses by RF Magnetron Sputter”, *2019 Optics & Photonics Taiwan, International Conference (OPTIC), 2019 Taichung Taiwan.*
- B19. W. H. Liao, C. K. Wang, Y. Z. Chiou, J. S. Jheng, S. P. Chang, and S. J. Chang, “The Study of $\text{ZnO}/\text{Mg}_x\text{Zn}_{1-x}\text{O}$ dual-band metal-semiconductor- metal photodetector with Different thicknesses by RF Magnetron Sputter”, *2019 10th International Conference on Molecular Electronics & BioElectronics (M&BE), 2019 Nara Japan.*
- B20. P. Y. Li, C. K. Wang, Y. Z. Chiou, J. S. Jheng, S. P. Chang, and S. J. Chang, “The Investigation of Optical Frequency Response of

InGaN/GaN Blue LEDs with Electron Retarded Layer in Low Temperature Environment”, *2018 Optics & Photonics Taiwan, International Conference (OPTIC), 2018 Tainan Taiwan.*

B21.P. Y. Li, Y. Z. Chiou, C. K. Wang, J. S. Jheng, S. P. Chang, and S. J. Chang, “Optical Frequency Response of GaN-Based Blue LEDs with an Electron Retarded Layer”, *2018 International Symposium on Novel and Sustainable Technology (ISNST), 2018 Tainan Taiwan.*

B22.W. H. Liao, C. K. Wang, Y. Z. Chiou, J. S. Jheng, S. P. Chang, and S. J. Chang, “MgZnO MSM Photodetector with Different Annealing Temperature”, *2018 International Symposium on Novel and Sustainable Technology (ISNST), 2018 Tainan Taiwan.*

B23.P. J. Sun, J. S. Jheng, C. K. Wang, and Y. Z. Chiou, “The investigation of Responsivity in GaN-based Metal-semiconductor-metal Ultraviolet Photodetector Using Trench Structure”, *2018 World Conference on Innovation, Engineering, and Technology (IET), 2018 Tokyo Japan.* (ISSN: 2518-0037)

B24.J. Y. Yang, Y. Z. Chiou, and C. K. Wang, “Characteristics of Different N-type Current Blocking Layers Designs for Ultraviolet GaN Vertical Light-emitting Diodes”, *2018 World Conference on Innovation, Engineering, and Technology (IET), 2018 Tokyo Japan.* (ISSN: 2518-0037)

B25.L. B. Chen, W. J. Chang, W. W. Hu, C. K. Wang, D. H. Lee, Y. Z. Chiou, “A Band-Pass IR Light Photodetector for Wearable Intelligent Glasses in a Drowsiness-Fatigue-Detection System”, *2018 IEEE International Conference on Consumer Electronics (ICCE), 2018 Las Vegas American.*

B26.S. S. Huang, Y. Z. Chiou, C. K. Wang, S. J. Chang, T. J. Hsueh, S. P. Chang, and S. M. Lin, “Preparation and characterization of tungsten trioxide (WO_3) thin films as the MEMS-type NO_x gas sensors”, *2017 International Conference Optics & Photonics Taiwan (OPTIC), 2017 Kaohsiung Taiwan.*

B27.S. H. Kao, K. W. Lin, C. K. Wang, and Y. Z. Chiou, “Study of the Optical and Response Characteristics of Green, Blue, and Ultraviolet Nitride-Based Light-Emitting Diodes”, *2017 International Workshop on UV Materials and Devices (IWUMD), 2017 Fukuoka Japan.*

B28.Z. X. Xu, C. K. Wang, Y. Z. Chiou, and Y. W. Wang, “Investigation of Nitride-Based Blue and Near Ultraviolet Flip Chip Light-Emitting Diodes”, *2017 International Symposium on Novel and Sustainable Technology (ISNST), 2017 Tainan Taiwan.* (ISBN: 978-986-5627-34-8)

B29.S. H. Kao, C. K. Wang, Y. Z. Chiou, and Y. H. Hsu, “The Study of Optical Properties of Nitride-Based Blue, Green, and Near Ultraviolet Light-Emitting Diodes”, *2017 International Symposium on Novel and Sustainable Technology (ISNST), 2017 Tainan Taiwan.* (ISBN: 978-986-5627-34-8)

B30.S. H. Chen, C. K. Wang, Y. Z. Chiou, K. C. Hung, and J. S. Jheng, “The Investigation of Efficiency Droop in GaN-Based Blue Light-Emitting Diode Using Hole Injection Layer with Different Mg-doped Concentrations”, *2017 International Symposium on Novel and Sustainable Technology (ISNST), 2017 Tainan Taiwan.* (ISBN: 978-986-5627-34-8)

B31.J. S. Jheng, C. K. Wang, Y. Z. Chiou, S. P. Chang, and S. J. Chang, “The Study of Optical and Response Characteristics in GaN-Based Blue Light-Emitting Diodes With an Electron Transmission Layer”, *2017 International Symposium on Novel and Sustainable Technology (ISNST), 2017 Tainan Taiwan.* (ISBN: 978-986-5627-34-8)

B32.T. J. Hsueh, S. P. Chang, S. S. Huang, Y. Z. Chiou, C. K. Wang, S. M. Lin, and S. J. Chang, “Fabrication of WO_3 sensing material as the MEMS type NO gas sensors”, *2017 International Symposium on Novel and Sustainable Technology (ISNST), 2017 Tainan Taiwan.* (ISBN: 978-986-5627-34-8)

B33.S. S. Huang, S. J. Chang, Y. Z. Chiou, C. K. Wang, T. J. Hsueh, and S. M. Lin, “Fabrication of Heterojunction of SnO₂/WO₃

sensing material as the MEMS type NO gas sensors”, *2017 9th International Symposium on Advanced Plasma Science and its Applications for Nitrides and Nanomaterials (ISPlasma), 2017 Aichi Japan.*

- B34. C. K. Wang, Y. W. Wang, Y. Z. Chiou, S. H. Chang, P. J. Sun, J. S. Jheng, S. P. Chang, and S. J. Chang, “Improvement of 370-nm InGaN/AlGaN Ultraviolet Light Emitting Diodes with Different Insertion Layer Thicknesses”, *2016 International Conference Optics & Photonics Taiwan (OPTIC), 2016 Taipei Taiwan.*
- B35. K. C. Hung, C. K. Wang, Y. Z. Chiou, J. Y. Yang, J. S. Jheng, S. P. Chang, and S. J. Chang, “Investigation of efficiency droop by simulated p-Al_xGa(1-x)N/In_yGa(1-y)N Molar Composition SPS-EBL for InGaN-based blue Light-Emitting Diodes”, *2016 International Conference Optics & Photonics Taiwan (OPTIC), 2016 Taipei Taiwan.*
- B36. C. K. Wang, J. S. Jheng, Y. Z. Chiou, S. P. Chang, and S. J. Chang, “GaN MIS Capacitors With ALD Al₂O₃ Insulator Layer”, *2016 International Electron Devices and Materials Symposium (2016 IEDMS), 2016 Taipei Taiwan.*
- B37. Y. Y. Chen, Y. Z. Chiou, and C. K. Wang, “Improved Metal Migration of the Electrode Reflector for GaN-based Blue Light Emitting Diodes”, *2016 29th International Microprocesses and Nanotechnology Conference (MNC 2016), 2016 Kyoto Japan.*
- B38. Y. H. Hsu, Y. Z. Chiou, and C. K. Wang, “Improvement of Quantum-Confining Stark Effect in InGaN/GaN Blue Light-Emitting Diodes with Partial Quantum Barrier Si-doping”, *2016 29th International Microprocesses and Nanotechnology Conference (MNC 2016), 2016 Kyoto Japan.*
- B39. K. W. Lin, C. K. Wang, Y. Z. Chiou, J. S. Jheng, S. P. Chang, and S. J. Chang, “The Effect of EQE and Frequency Response on GaN-Based Light-Emitting Diodes with Chip Sizes Modulation”, *2016 The 15th International Symposium on Advanced Technology (ISAT-15), 2016 Tainan Taiwan.*
- B40. K. W. Lin, C. K. Wang, Y. Z. Chiou, J. S. Jheng, S. P. Chang, and S. J. Chang, “The Investigation Of Frequency Response On GaN-Based Blue LEDs With Different Chip Sizes”, *2016 International Symposium on Novel and Sustainable Technology (ISNST), 2016 Tainan Taiwan.*
- B41. Y. W. Wang, S. H. Chang, Y. Z. Chiou, and C. K. Wang, “Suppression of Electron Overflow in 370-nm InGaN/AlGaN Ultraviolet Light Emitting Diodes with Different Insert Layer Thicknesses”, *2016 The 18th International Conference on Crystal Growth and Epitaxy (ICCGE-18), 2016 Nagoya Japan.*
- B42. K. C. Hung, C. K. Wang, and Y. Z. Chiou, “Suppressing Efficiency Droop Using Graded AlGaN/InGaN Superlattice Electron Blocking Layer for InGaN-based Light-Emitting Diodes”, *2016 The 18th International Conference on Crystal Growth and Epitaxy (ICCGE-18), 2016 Nagoya Japan.*
- B43. P. K. Lin, C. K. Wang, Y. Z. Chiou, S. P. Chang, and S. J. Chang, “GaN-based Ultraviolet Light-Emitting Diodes with P-AlGaN/GaN Superlattice EBL”, *2015 International Conference Optics & Photonics Taiwan (OPTIC), 2015 Hsinchu Taiwan.*
- B44. K. W. Chiang, Y. Z. Chiou, C. K. Wang, S. P. Chang, and S. J. Chang, “Investigation the Effect of GaN-based Ultraviolet Light-Emitting Diodes with Different Thickness of the Electron Blocking Layer”, *2015 International Conference Optics & Photonics Taiwan (OPTIC), 2015 Hsinchu Taiwan.*
- B45. P. K. Lin, C. K. Wang, Y. Z. Chiou, S. P. Chang, and S. J. Chang, “Efficiency enhancement of an Blue InGaN Light Emitting Diode With p-InGaN/GaN SPS Last Barrier and p-AlGaN/GaN SPS EBL”, *2015 The 6th International Symposium on Growth of III-Nitrides (ISGN-6), 2015 Hamamatsu Japan.*
- B46. K. W. Chiang, C. K. Wang, Y. Z. Chiou, S. W. Wang, and S. J. Chang, “Investigation the effect of Nitride-based LEDs Using Hole Injection Layer with different growing temperature”, *2015 The 6th International Symposium on Growth of III-Nitrides (ISGN-6), 2015 Hamamatsu Japan.*

- B47. S. W. Yang, C. K. Wang, Y. Z. Chiou, S. P. Chang, and S. J. Chang, "Investigation of InGaN/GaN Blue and Green Light-Emitting Diodes With Different Electron Blocking Layer Thicknesses", *2015 The 6th International Symposium on Growth of III-Nitrides (ISGN-6), 2015 Hamamatsu Japan.*
- B48. P. K. Lin, C. K. Wang, Y. Z. Chiou, S. P. Chang, and S. J. Chang, "Performance Enhancement of Blue InGaN Light-Emitting Diodes with p-InGaN/GaN SPS Last Barrier and p-AlGaN/GaN SPS EBL", *2015 International Conference on Solid State Devices and Materials (SSDM), 2015 Sapporo Japan.* (ISBN: 978-4-86348-514-3)
- B49. Y. W. Lin, C. K. Wang, Y. Z. Chiou, H. M. Chang, S. J. Chang, H. J. Chang, C. P. Hung, and Y. D. Wu, "Investigation of the optical and electrical properties of GaN-based blue light-emitting diodes with various quantum well thickness", *2015 Seoul International Conference on Engineering and Applied Science (SICEAS), 2015 Seoul South Korea.* (ISBN: 978-986-5654-09-2)
- B50. C. P. Hung, S. W. Wang, C. K. Wang, Y. Z. Chiou, S. J. Chang, H. J. Chang, Y. W. Lin, and Y. D. Wu, "Effect of Mg doping in the Last Barrier on Optical and Electrical Properties of InGaN/GaN MQW Blue Light-Emitting Diodes", *2015 Seoul International Conference on Engineering and Applied Science (SICEAS), 2015 Seoul South Korea.* (ISBN: 978-986-5654-09-2)
- B51. H. J. Chang, S. W. Wang, C. K. Wang, Y. Z. Chiou, S. J. Chang, Y. W. Lin, C. P. Hung, and Y. D. Wu, "Temperature-Dependent Electroluminescence in Nitride-Based Blue LEDs with Different Barrier Growth Rate", *2015 Seoul International Conference on Engineering and Applied Science (SICEAS), 2015 Seoul South Korea.* (ISBN: 978-986-5654-09-2)
- B52. Y. D. Wu, S. W. Wang, C. K. Wang, Y. Z. Chiou, S. J. Chang, Y. W. Lin, C. P. Hung, and H. J. Chang, "The Study of the Efficiency Droop in Nitride-based LEDs Using Hole Injection Layer with Different Thickness", *2015 Seoul International Conference on Engineering and Applied Science (SICEAS), 2015 Seoul South Korea.* (ISBN: 978-986-5654-09-2)
- B53. S. B. Chuang, C. K. Wang, Y. Z. Chiou, C. H. Yen, W. C. Lai, and S. J. Chang, "Enhancement in Output Power of Blue Nitride-based Light Emitting Diodes with an Electron Retarded Layer", *2014 International Conference Optics & Photonics Taiwan (OPTIC), 2014 Taichung Taiwan.*
- B54. H. J. Chang, C. K. Wang, Y. Z. Chiou, and K. W. Lin, "The Optical Properties of Nitride-based Blue LEDs with Lateral and Vertical Type Structures", *2014 International Symposium on Nano Science and Technology (ISNST), 2014 Tainan Taiwan.*
- B55. C. P. Hung, C. K. Wang, Y. Z. Chiou, and K. W. Lin, "Improvement of Thermal Effect and Current Crowding Effect of GaN-based Green LEDs by Vertical Structure", *2014 International Symposium on Nano Science and Technology (ISNST), 2014 Tainan Taiwan.*
- B56. Y. D. Wu, S. W. Wang, C. K. Wang, and Y. Z. Chiou, "The Study of the Efficiency Droop in Nitride-based LEDs using Hole Injection Layer with Different Thickness", *2014 International Symposium on Nano Science and Technology (ISNST), 2014 Tainan Taiwan.*
- B57. Y. W. Lin, C. K. Wang, Y. Z. Chiou, H. M. Chang, S. P. Chang, and S. J. Chang, "Investigation of the Optical and Electrical Properties of GaN-based Blue Light-emitting Diodes with Various Quantum Well Thickness", *2014 International Symposium on Nano Science and Technology (ISNST), 2014 Tainan Taiwan.*
- B58. J. S. Jheng, C. K. Wang, Y. Z. Chiou, T. K. Lin, and S. J. Chang, "The Improvement of Efficiency Droop and Current Spreading on Nitride-based LEDs Using Electron Transmission Layer", *Conference on LED and Its Industrial Application' 14 (LEDIA'14), 2014 Yokohama Japan.*
- B59. S. B. Chuang, C. K. Wang, Y. Z. Chiou, C. H. Yen, W. C. Lai, and S. J. Chang, "Enhancement in Output Power of Blue Nitride-based Light Emitting Diodes with an Electron Retarded Layer", *Conference on LED and Its Industrial Application' 14 (LEDIA'14), 2014 Yokohama Japan.*

- B60.J. Lee, C. H. Yen, W. C. Lai, Y. Y. Yang, C. K. Wang, and S. J. Chang, “Efficiency Improvement of Nitride-Based Light-Emitting Diode With Physical Vapor Deposition AlN Nucleation Layer”, *Conference on LED and Its Industrial Application’ 14 (LEDIA’ 14), 2014 Yokohama Japan.*
- B61.Y. T. Huang, Y. Z. Chiou, C. K. Wang, and T. K. Ko, “Enhancement of Light Output Power of GaN-Based Light-Emitting Diodes by Optimized Design of High Reflection Electrode Under Metal Pad”, *2014 9th International Conference on Optics-photonics Design & Fabrication (ODF), 2014 Tokyo Japan.* (ISBN: 978-4-86348-400-9)
- B62.C. C. Hung, C. K. Wang, Y. Z. Chiou, C. H. Yen, T. H. Chiang, and S. J. Chang, “Improved Performance of GaN Metal-Semiconductor-Metal Photodetectors with Sputtered AlN Nucleation Layer”, *2013 International Conference Optics & Photonics Taiwan (OPTIC), 2013 Zhongli Taiwan.*
- B63.Y. T. Huang, Y. Z. Chiou, C. K. Wang, and T. K. Ko, “Enhancement of Light Output Power of GaN-Based Light-Emitting Diodes by Optimized Design of High Reflection Electrode Under Metal Pad”, *2013 International Conference Optics & Photonics Taiwan (OPTIC), 2013 Zhongli Taiwan.*
- B64.W. C. Jan, C. K. Wang, Y. Z. Chiou, T. K. Ko, T. H. Chiang, and S. J. Chang, “The Effect of Electro-optical Properties and Electrostatic Discharge Characteristic on GaN-based LEDs with Sidewall Phosphoric Etching Treatment”, *2013 International Conference Optics & Photonics Taiwan (OPTIC), 2013 Zhongli Taiwan.*
- B65.C. C. Hsiang, C. K. Wang, Y. Z. Chiou, W. Y. Yan, T. H. Chiang, and S. J. Chang, “Performance Improvement of Near-UV Nitride-based Light Emitting Diodes with Different Aluminum Composition Barrier Structure”, *2013 International Conference Optics & Photonics Taiwan (OPTIC), 2013 Zhongli Taiwan.*
- B66.B. J. Hu, Y. Z. Chiou, C. K. Wang, T. K. Ko, and T. H. Chiang, “Using Optimal Design of Current Blocking Layer to Improve the Spreading Length on GaN-Based Light Emitting Diodes”, *2013 International Conference Optics & Photonics Taiwan (OPTIC), 2013 Zhongli Taiwan.*
- B67.C. C. Hsiang, C. K. Wang, and Y. Z. Chiou, “Enhancement of Optical Performance of Near-UV Nitride-based Light Emitting Diodes with Different Aluminum Composition Barrier Structure”, *2013 International Symposium on Nano Science and Technology (ISNST), 2013 Tainan Taiwan.*
- B68.C. C. Hsiang, C. K. Wang, Y. Z. Chiou, J. Lee, J. J. Tang, W. S. Chen, C. M. Cheng, D. H. Lee, K. H. Chen, and W. Y. Yan, “Enhancement of Optical Performance of Near-UV Nitride-based Light Emitting Diodes with Different Aluminum Composition Barrier Structure”, *2013 The 2nd International Conference on Advanced Electromaterials (ICAЕ), 2013 Jeju Korea.*
- B69.C. H. Pei, K. H. Chen, M. C. Kuan, C. K. Wang, and C. M. Cheng, “(1-x)K_{0.5}Na_{0.5}Ta_{0.1}Nb_{0.9}O₃+xBaTiO₃ Lead-Free Piezoelectric Ceramics”, *2013 The 2nd International Conference on Advanced Electromaterials (ICAЕ), 2013 Jeju Korea.*
- B70.C. M. Cheng, M. C. Kuan, C. H. Pei, K. H. Chen, and C. K. Wang, “Lead-Free Piezoelectric Ceramics (Ba_{0.92}Ca_{0.08})(Ti_{1-x}Zr_x)O₃”, *2013 The 2nd International Conference on Advanced Electromaterials (ICAЕ), 2013 Jeju Korea.*
- B71.C. C. Hung, C. K. Wang, Y. Z. Chiou, C. H. Yen, T. H. Chiang, and S. J. Chang, “Performance Improvement of GaN Metal-Semiconductor-Metal Photodetectors with Sputtered AlN Nucleation Layer”, *2013 International Conference on Solid State Devices and Materials (SSDM), 2013 Fukuoka Japan.* (ISBN: 978-4-86348-362-0)
- B72.W. C. Jian, C. K. Wang, Y. Z. Chiou, T. K. Ko, S. J. Chang, T. H. Chiang, and S. P. Chang, “Improved Light Output Power of GaN-based Light-Emitting Diodes with Sidewall Acid-Etching Treatment”, *2013 The 6th Asia-Pacific Workshop on Widegap Semiconductors (APWS), 2013 New Taipei City Taiwan.*
- B73.C. K. Wang, Y. Z. Chiou, J. Lee, J. J. Tang, W. S. Chen, C. M. Cheng, D. H. Lee, T. H. Chiang, S. J. Chang, and K. H. Chen,

"Investigated the Current Spreading and Thermal Effect on Nitride-based Light Emitting Diodes by Surface Thermal Images Analysis", *2013 Annual International Conference on Optoelectronics, Photonics & Applied Physics (OPAP), 2013 Singapore*. (ISSN: 2301-3516)

B74. **C. K. Wang**, Y. Z. Chiou, J. Lee, J. J. Tang, W. S. Chen, C. M. Cheng, D. H. Lee, T. H. Chiang, S. J. Chang, T. K. Lin, and K. H. Chen, "The Effect of Varied Last Barrier Thickness on ESD and Optical Properties of GaN-based LEDs", *2013 Annual International Conference on Optoelectronics, Photonics & Applied Physics (OPAP), 2013 Singapore*. (ISSN: 2301-3516)

B75. **C. K. Wang**, Y. Z. Chiou, T. H. Chiang, S. J. Chang, S. P. Chang, and Y. K. Lin, "Investigate the Carrier Blocking Capability of Electron Blocking Layer on Nitride-Based LEDs with Different Aluminum Mole", *2013 International Symposium on Advanced Plasma Science and its Applications for Nitrides and Nanomaterials (ISPlasma), 2013 Nagoya Japan*.

B76. **C. K. Wang**, Y. Z. Chiou, T. H. Chiang, S. J. Chang, T. K. Ko, and S. P. Chang, "Investigated the Effect of Different Electrode Length Designs on Nitride-based Light Emitting Diodes", *2013 International Symposium on Advanced Plasma Science and its Applications for Nitrides and Nanomaterials (ISPlasma), 2013 Nagoya Japan*.

B77. **C. K. Wang**, Y. Z. Chiou, T. H. Chiang, S. J. Chang, S. P. Chang, T. K. Ko, C. H. Hsieh, H. C. Hsiao, and Y. Y. Lin, "Investigated the Current Spreading and Output Power on Nitride-based Light Emitting Diodes by Surface Thermal Images Analysis", *2013 International Symposium on Advanced Plasma Science and its Applications for Nitrides and Nanomaterials (ISPlasma), 2013 Nagoya Japan*.

B78. C. Y. Chu, **C. K. Wang**, Y. Z. Chiou, T. K. Lin, T. H. Chiang, S. P. Chang, and S. J Chang, "Efficiency Improvement of Nitride-based LEDs with Different Last Barrier Thicknesses", *2012 International Conference Optics & Photonics Taiwan (OPTIC), 2012 Taipei Taiwan*.

B79. C. C. Hon, **C. K. Wang**, Y. Z. Chiou, T. K. Lin, T. H. Chiang, S. P. Chang, and S. J Chang, "Reduction of Efficiency Droop in Nitride-based Blue LEDs with p-Type GaN Electron Retarded Layer", *2012 International Conference Optics & Photonics Taiwan (OPTIC), 2012 Taipei Taiwan*.

B80. **C. K. Wang**, Y. Z. Chiou, D. J. Sun, and T. H. Chiang, "Low Dislocation Densities on Nitride-based LEDs with a Preflow of NH₃ Source Before Growth of AlN Buffer Layer", *2012 International Symposium on Advanced Plasma Science and its Applications for Nitrides and Nanomaterials (ISPlasma), 2012 Aichi Japan*.

B81. **C. K. Wang**, Y. Z. Chiou, S. P. Chang, and T. H. Chiang, "Reducing the Current Crowding Effect on Nitride-based LEDs using Modulated P-extension Electrode Thickness", *2012 International Symposium on Advanced Plasma Science and its Applications for Nitrides and Nanomaterials (ISPlasma), 2012 Aichi Japan*.

B82. Y. Z. Chiou, H. Y. Chiou, T. H. Chiang, **C. K. Wang**, T. K. Ko, S. J. Chang, and S. P. Chang, "Investigation of P-extension Electrode Thickness for Nitride-based Light Emitting Diode", *2011 International Electron Devices and Materials Symposium (IEDMS), 2011 Taiwan*.

B83. Y. Z. Chiou, T. H. Chiang, C. H. Wang, **C. K. Wang**, T. K. Ko, T. K. Lin, C. J. Chiu, and S. P. Chang, "Improving the Optical Characteristics and Electrostatic Discharge Endurance of Nitride based LEDs by using N minus layer", *2011 3rd International Symposium on Advanced Plasma Science and its Applications for Nitrides and Nanomaterials (ISPlasma), 2011 Nagoya*.

B84. Y. Z. Chiou, Y. C. Chiang, T. H. Chiang, **C. K. Wang**, T. K. Ko, T. K. Lin, and S. P. Chang, "Improvement on Optical Property of Nitride-Based Light Emitting Diodes with Silicon Doped Quantum Barriers", *2010 International Conference on Manufacturing and Engineering Systems, 2010 Tainan*.

B85. J. K. Lee, Y. Z. Chiou, **C. K. Wang**, T. K. Ko, T. K. Lin, S. P. Chang, and T. H. Chiang, "The Effect of different electrode length

designs on Large Nitride-based Light Emitting Diodes”, *2010 International Conference on Manufacturing and Engineering Systems, 2010 Tainan*.

- B86. Y. T. Lee, Y. Z. Chiou, C. K. Wang, T. K. Ko, T. K. Lin, S. P. Chang, and T. H. Chiang, “Improvement of the Light Output Intensity on Nitride-Based Diodes by Ar+ Plasma Etched Current Blocking Layer”, *2010 International Conference on Manufacturing and Engineering Systems, 2010 Tainan*.
- B87. Y. T. Lee, S. J. Chang, C. K. Wang, T. K. Ko, T. K. Lin, S. P. Chang, T. H. Chiang, and Y. Z. Chiou, “Improvement in Optical Property on Nitride-Based Light Emitting Diodes by Doping Silicon in Quantum Barriers”, *2010 International Conference on Optics and Photonics, 2010 Tainan*
- B88. T. H. Chiang, S. J. Chang, C. K. Wang, T. K. Ko, T. K. Lin, S. P. Chang, and Y. Z. Chiou, “Improvement of Current Spreading on Nitride-based Light Emitting Diodes Using n-GaN Layer”, *2010 International Conference on Optics and Photonics, 2010 Tainan*.
- B89. C. K. Wang, D. S. Kuo, T. K. Ko, W. Y. Yen, and S. J. Hon, “Enhanced light output of InGaN-based light emitting diodes with micro-void buffer structure”, *2009 International Conference on White LEDs and Solid State Lighting, 2009 Taipei*.
- B90. Y. Z. Chiou, H. W. Shih, T. K. Ko, and C. K. Wang, “The Characteristics of GaN MSM Photodetectors Prepared on Silicon and Sapphire Substrate”, *2008 International Conference on Functional Materials and Devices, 2008 Kuala Lumpur, Malaysia*.
- B91. Y. Z. Chiou, T. K. Lin, C. Y. Lu, S. P. Chang, C. K. Wang, C. F. Kuo, and H. M. Chang, “The Characteristics of Transparent Metal-ZnO Contacts and ZnO-based Photodiodes”, *2007 SPIE Conference Proceedings, 2007 USA*.
- B92. Y. Z. Chiou, T. K. Ko, C. K. Wang, T. K. Lin, and K. W. Lin, “Leakage current analysis of nitride based optoelectronics by emission microscopy inspection”, *2007 Asia-Pacific Microwave Conference, 2007 Bangkok, Thailand*.
- B93. C. K. Wang, S. J. Chang, Y. K. Su, Y. Z. Chiou, T. K. Lin, T. K. Ko, H. Li. Liu, and J. J. Tang, “Noise analysis of nitride-based MOS-HFETs with photo-chemical vapor deposition SiO₂ gate oxide in the linear and saturation region”, *2005 International Conference on Solid State Devices and Materials, pp. 1066-1067, 2005 SSDM*.
- B94. Y. Z. Chiou, Y. K. Su, S. J. Chang, C. K. Wang, and J. J. Tang, “The annealing effects of GaN MIS capacitors with Photo-CVD oxide layers”, *2005 International Conference on Solid State Devices and Materials, pp. 568-569, 2005 SSDM*.
- B95. T. K. Lin, S. J. Chang, Y. K. Su, Y. Z. Chiou, C. K. Wang, S. P. Chang, J. J. Tang, and B. R. Huang, “Homoepitaxial ZnSe MIS photodetectors using SiO₂ and BST insulator”, *2005 International Conference on Solid State Devices and Materials, pp. 746-747, 2005 SSDM*.
- B96. C. K. Wang, S. J. Chang, Y. Z. Chiou, T. K. Lin, C. S. Chang, J. J. Wong, H. L. Liu, S. P. Chang, and J. J. Tang, “AlGaN/GaN MOS-HFETs with room temperature Photo-CVD SiO₂ layer”, *2005 6th Topical Workshop on Heterostructure Microelectronics, 2005 TWHM*.
- B97. Y. Z. Chiou, S. J. Chang, and C. K. Wang, “GaN MIS capacitors with room-temperature grown SiO₂ insulator by using photo-chemical vapor deposition”, *2005 6th Topical Workshop on Heterostructure Microelectronics, 2005 TWHM*.
- B98. T. K. Lin, S. J. Chang, Y. Z. Chiou, C. K. Wang, and S. P. Chang, “ZnSe MSM photodetectors prepared on GaAs and ZnSe substrates”, *2005 6th Topical Workshop on Heterostructure Microelectronics, 2005 TWHM*.
- B99. S. J. Chang, W. S. Chen, Y. K. Su, Y. C. Lin, C. S. Chang, T. K. Ke, Y. P. Hsu, C. F. Shen, J. M. Tasi, T. K. Lin, C. K. Wang, and S. C. Shei, “Nitride-based flip-chip light-emitting diodes with reflective mirror and transparent ohmic contact layer”, *2005 6th Topical Workshop on Heterostructure Microelectronics, 2005 TWHM*.
- B100. C. K. Wang, S. J. Chang, Y. K. Su, Y. Z. Chiou, C. H. Kuo, C. S. Chang, T. K. Lin, T. K. Ko, and J. J. Tang, “High temperature

and low frequency noise of AlGaN/GaN/AlGaN double heterostructure MOS-HFETs with photo-chemical vapor deposition SiO₂ layer”, *2004 International Conference on Solid State Devices and Materials*, pp. 270-271, 2004 SSDM.

B101. Y. Z. Chiou, C. K. Wang, S. J. Chang, Y. K. Su, C. S. Chang, T. K. Lin, T. H. Fang, and J. J. Tang, “Noise analysis of AlGaN/GaN MOS-HFETs with photo-chemical vapor deposition SiO₂ layer”, *2004 International Conference on Solid State Devices and Materials*, pp. 272-273, 2004 SSDM.

B102. C. K. Wang, H. L. Liu, S. J. Chang, Y. K. Su, C. S. Chang, Y. Z. Chiou, C. H. Kuo, T. K. Lin, and J. J. Tang, “Transparent TiW electrodes in GaN metal-semiconductor-metal UV photodetectors”, *2004 3rd Asian Chemical Vapor Deposition International Conference, 2004 ACVD*.

B103. C. K. Wang, S. J. Chang, Y. K. Su, Y. Z. Chiou, T. K. Lin, and B. R. Huang, “Low interface state density AlGaN/GaN MOSHFETs with photochemical vapor deposition SiO₂ layers”, *2003 International Conference on Nitride Semiconductors, 2003 ICNS-5*.

B104. C. S. Chang, S. J. Chang, Y. K. Su, W. C. Lai, C. H. Kuo, C. K. Wang, Y. C. Lin, Y. P. Hsu, S. C. Shei, H. M. Lo, J. C. Ke, and J. K. Sheu, “High brightness InGaN/GaN LEDs with indium-tin-oxide as p-electrode”, *2003 International Conference on Nitride Semiconductors, 2003 ICNS-5*.

B105. C. H. Kuo, S. J. Chang, Y. K. Su, C. K. Wang, L. W. Wu, J. K. Sheu, and J. M. Tasi, “Nitride-based blue LEDs withGaN/SiN double buffer layers”, *2003 International Conference on Solid State Devices and Materials, 2003 SSDM*.

C. 專利發明

- C1. 王俊凱, 邱裕中, “可攜式懸浮微粒成份偵測裝置”, *TW patent No. I691712* (2020)
- C2. 邱裕中, 王俊凱, 傅顯智, “光學式氣體微量濃度偵測裝置”, *TW patent No. I668427* (2019)
- C3. 邱裕中, 王俊凱, 傅顯智, “高精準度光學空氣微粒偵測裝置”, *TW patent No. I668424* (2019)
- C4. 王俊凱, 邱裕中, “砷化鎵之帶通型紅光與紅外光檢測器”, *TW patent No. I661571* (2019)
- C5. 王俊凱, 邱裕中, 林冠緯, 林義國, “氮化物發光二極體之電極結構”, *TW patent No. I603501* (2017)
- C6. 邱裕中, 王俊凱, 林冠緯, “水平式氮化物發光二極體”, *TW patent No. I566428* (2017)
- C7. 邱裕中, 王俊凱, 林冠緯, “垂直式氮化物發光二極體的製造方法”, *TW patent No. I517475* (2016)
- C8. 王俊凱, 邱裕中, 蔣宗勳, 洪峻棋, 簡瑋辰, 向勁齊, “可防止電子溢流之 III-V 族發光二極體”, *TW patent No. I517438* (2016)
- C9. 王俊凱, 邱裕中, 林冠緯, “III-V 族發光二極體之電極”, *TW patent No. I497767* (2015)
- C10. 彭韋智, 謝明勳, 許明祺, 顏偉昱, 王俊凱, 陳彥志, 洪詳竣, “光電元件及其製造方法”, *CN patent No. 102623580* (2015)
- C11. 柯丁嘉, 沈建賦, 顏偉昱, 郭得山, 林予堯, 王俊凱, “光電元件”, *TW patent No. I483424* (2015)
- C12. 王俊凱, 洪詳竣, 許育賓, 朱瑞溢, 吳欣顯, 顏偉昱, “發光元件”, *CN patent No. 101740668* (2014)
- C13. 彭韋智, 謝明勳, 許明祺, 顏偉昱, 王俊凱, 陳彥志, 洪詳竣, “光電元件及其製造方法”, *TW patent No. I451597* (2014)
- C14. 王俊凱, 洪詳竣, 許育賓, 朱瑞溢, 吳欣顯, 顏偉昱, “發光元件”, *TW patent No. I446572* (2014)
- C15. J. H. Yeh, C. K. Wang, W. Y. Yen, Y. Y. Lin, C. F. Shen, D. S. Kuo, T. C. Ko, “Light-emitting Element and The Manufacturing Method Thereof”, *US patent No. 8754439 B2* (2014)
- C16. J. Y. Chu, C. T. Kuo, Y. P. Hsu, C. K. Wang, H. H. Wu, Y. C. Lin, “Opto-Electronic Device”, *US patent No. 8729525 B2* (2014)

- C17. C. K. Wang, S. J. Hon, Y. P. Hsu, J. Y. Chu, H. H. Wu, W. Y. Yen, "Light Emitting Device", *US patent No.8704252 B2* (2014)
- C18. 郭政達, 許育賓, 王俊凱, 朱瑞溢, 陳宗光, "發光二極管的結構", *CN patent No. 1298746* (2013)
- C19. W. C. Peng, M. H. Hsieh, M. C. Hsu, W. Y. Yen, C. K. Wang, Y. C. Chen, S. J. Hon, H. Y. Wang, C. K. Chung, "Optoelectronic Device and Method for Manufacturing The Same", *US patent No. 8519430 B2* (2013)
- C20. 朱瑞溢, 郭政達, 許育賓, 王俊凱, 吳欣顯, 林義傑, "光電元件", *TW patent No. I389344* (2013)
- C21. 郭政達, 許育賓, 王俊凱, 朱瑞溢, 陳宗光, "發光二極體元件及其製造方法", *TW patent No. I364119* (2012)
- C22. 林義傑, 郭政達, 許育賓, 朱瑞溢, 王俊凱, "半導體元件", *TW patent No. I362124* (2012)
- C23. 朱瑞溢, 郭政達, 許育賓, 王俊凱, 吳欣顯, 林義傑, "光電元件", *CN patent No. 857830* (2011)
- C24. 林義傑, 郭政達, 許育賓, 朱瑞溢, 王俊凱, "半導體元件", *CN patent No. 799291* (2011)
- C25. C. T. Kuo, Y. P. Hsu, C. K. Wang, J. Y. Chu, T. K. Chen, "Light Emitting Diode Device That Includes a Three Dimensional Cloud Structure and Manufacturing Method Thereof", *US patent No. 7902562 B2* (2011)
- C26. 王俊凱, 洪詳竣, 許育賓, 朱瑞溢, 顏偉昱, 吳欣顯, "一具有高發光效率的發光元件", *TW patent No. M394576* (2010)
- C27. 許育賓, 郭政達, 朱瑞溢, 王俊凱, "發光元件及其製造方法", *TW patent No. I313076* (2009)
- C28. 郭政達, 許育賓, 王俊凱, 朱瑞溢, 陳宗光, "基板結構及其製造方法與應用", *TW patent No. I310249* (2009)
- C29. 蘇炎坤, 張守進, 邱裕中, 王俊凱, 林天坤, "光檢測器及其製造方法", *TW patent No. I281267* (2007)

D. 國科會計畫

- D1. 專題研究計畫(一般研究計畫), 計畫主持人, 【藉由高功函數過渡金屬及插入一層濺鍍氧化鎵薄膜來提升蕭特基能障並應用於具有特殊場板結構之高崩潰電壓垂直式氧化鎵蕭特基二極體之研製】 , NSTC 113-2221-E-218-013 , 113/08/01~114/07/31 (915,000 元)
- D2. 專題研究計畫(一般研究計畫), 計畫主持人, 【以射頻磁控濺鍍法在不同基板上研製出高品質之氧化鎵深紫外光檢測器並研發氧化鎵薄膜之鎵空缺及氧空缺修補技術】 , MOST 111-2221-E-218-005 , 111/08/01~112/07/31 (1,000,000 元)
- D3. 專題研究計畫(一般策略專案計畫), 共同主持人, 【智慧光學式二氧化氮氣體感測系統(1/4)】 , MOST 110-2218-E-218-002-MBK , 110/11/01~111/05/31 (2,602,000 元)
- D4. 專題研究計畫(一般研究計畫), 計畫主持人, 【利用原子層沉積系統成長高品質之氧化鎵薄膜並製作具有場板結構之第四代高功率氧化鎵增強型金氧半場效電晶體】 , MOST 110-2221-E-218-013 , 110/08/01~111/07/31 (756,000 元)
- D5. 專題研究計畫(產學技術聯盟合作計畫), 共同主持人, 【AIoT 智慧聯網應用技術研發聯盟(3/3)】 , MOST 110-2622-8-218-002-TE2 , 110/02/01~111/01/31 (2,100,000 元)
- D6. 專題研究計畫(產學技術聯盟合作計畫), 共同主持人, 【AIoT 智慧聯網應用技術研發聯盟(2/3)】 , MOST 109-2622-8-218-003-TE2 , 109/02/01~110/01/31 (2,300,000 元)
- D7. 專題研究計畫(一般研究計畫), 計畫主持人, 【利用氧化鎳薄膜及奈米柱結構研製高性能之酸鹼值感測器】 , MOST 118-2221-E-218-022 , 108/08/01~109/07/31 (906,000 元)
- D8. 專題研究計畫(產學技術聯盟合作計畫), 共同主持人, 【AIoT 智慧聯網應用技術研發聯盟(1/3)】 , MOST 108-2622-8-218-004-TE2 , 108/02/01~109/01/31 (2,310,000 元)
- D9. 專題研究計畫(一般研究計畫), 計畫主持人, 【利用射頻磁控濺鍍系統研製高品質氧化鎂鋅 3D 鮋式薄膜電晶體及雙波段光檢測器】 , MOST 107-2221-E-218-011 , 107/08/01~108/07/31 (900,000 元)

- D10. 專題研究計畫(一般研究計畫)，計畫主持人，【利用有機金屬化學氣相沉積法及離子束濺鍍法製作高品質氧化鎂鋅之3D 鮮式薄膜電晶體】，MOST 106-2221-E-218-027，106/08/01~107/07/31 (915,000 元)
- D11. 專題研究計畫(一般研究計畫)，共同主持人，【應用於駕駛行車安全之智慧眼鏡穿戴式裝置及其雲端管理平台研製】，MOST 106-2218-E-218-004，106/08/01~107/07/31 (3,049,000 元)
- D12. 專題研究計畫(新進人員研究計畫)，計畫主持人，【利用原子層沉積法成長出超高品质的氧化鋁與氧化鎵之氧化層薄膜並應用於氮化鎵系列金氧半異質接面場效電晶體之研製】，MOST 104-2221-E-218-020-MY2，104/08/01~106/07/31 (1,813,000 元)
- D13. 專題研究計畫(新進人員研究計畫)，計畫主持人，【利用物理氣相沉積法在不同基板上製作氮化鋁緩衝層薄膜之研製並應用於氮化鎵系列紫外光檢測器及發光二極體】，NSC 101-2221-E-218-023-MY2，101/08/01~103/07/31 (1,753,000 元)
- D14. 專題研究計畫(提升私校研發能量專案計畫)，共同主持人，【應用於低碳智慧電子系統之多功能能量採集器】，NSC 101-2632-E-218-001-MY3，101/08/01~104/07/31 (12,840,000 元)
- D15. 專題研究計畫(新進人員研究計畫)，計畫主持人，【氮化鎵系列發光二極體在超高電流密度操作下其發光效率驟減之研究與改善】，NSC 100-2218-E-218-002，100/10/01~101/08/31 (771,000 元)

E. 其他政府部門計劃

- E1. 國家實驗研究院 AQI 氣體感測器服務平台專案計畫(3/3)，共同主持人，【光學式二氧化氮氣體偵測以及 PM2.5 成分辨識系統】，NARL-AOI-109-003，109/09/01~110/05/31 (1,800,000 元)
- E2. 國家實驗研究院 AQI 氣體感測器服務平台專案計畫(2/3)，共同主持人，【光學式二氧化氮氣體偵測以及 PM2.5 成分辨識系統】，NARL-AOI-108-003，108/09/01~109/08/31 (2,160,000 元)
- E3. 國家實驗研究院 AQI 氣體感測器服務平台專案計畫(1/3)，計畫主持人，【光學式 PM2.5 濃度及成分辨識系統】，NARL-AOI-107-006，107/11/01~108/08/31 (1,620,000 元)
- E4. 國家實驗研究院物聯網感測器服務平台專案，共同主持人，【乘載於無人飛行器之可攜式光學空氣品質監測系統】，NARL-IOT-106-014，106/06/01~107/05/31 (1,400,000 元)

F. 產學計畫

- F1. 光鎧科技股份有限公司，【2022 第三季光鎧科技良率提升開發計畫】，計畫主持人，12001110227，111/07/01~112/06/30 (600,000 元)
- F2. 聯勝光電股份有限公司，【聯勝光電發光及雷射二極體之晶粒開發計畫】，計畫主持人，12001100032，110/01/01~110/12/31 (400,000 元)
- F3. 聯勝光電股份有限公司，【聯勝光電發光二極體之元件故障分析計畫】，計畫主持人，12001091015，109/06/01~110/05/31 (200,000 元)
- F4. 愛迪佳科技有限公司，【不鏽鋼電漿拋光樣品分析計畫】，計畫主持人，12001080317，108/08/01~109/07/31 (300,000 元)
- F5. 立創光電股份有限公司，【光學式懸浮微粒濃度及成分偵測技術】，計畫主持人，12001080162，108/04/01~109/03/31 (600,000 元，含技轉金額: 200,000 元)
- F6. 聯勝光電股份有限公司，【聯勝光電發光二極體之可靠度提升計畫】，計畫主持人，12001080046，108/02/01~108/12/31 (500,000 元)
- F7. 聯勝光電股份有限公司，【聯勝光電發光二極體之晶粒分析計畫】，計畫主持人，12001070377，107/10/01~108/12/31 (600,000 元)

- F8. 聯勝光電股份有限公司，【聯勝光電發光二極體之元素分析計畫】，計畫主持人，12001070376，107/10/01~107/12/31 (100,000 元)
- F9. 奇景光電股份有限公司，【2018 奇景光電積體電路良率提升計畫】，計畫主持人，12001070249，107/08/01~108/07/31 (500,000 元)
- F10. 聯勝光電股份有限公司，【聯勝光電發光二極體之元件分析計畫】，計畫主持人，12001070024，107/01/01~107/12/31 (200,000 元)
- F11. 聯勝光電股份有限公司，【聯勝光電發光二極體之故障分析計畫】，計畫主持人，12001070008，107/01/01~107/12/31 (500,000 元)
- F12. 奇景光電股份有限公司，【2017 奇景光電積體電路良率提升計畫】，計畫主持人，131060216，106/08/01~107/07/31 (500,000 元)
- F13. 聯勝光電股份有限公司，【聯勝光電發光二極體之可靠度分析計畫】，計畫主持人，131060113，106/05/01~107/04/30 (360,000 元)
- F14. 奇景光電股份有限公司，【2016 奇景光電積體電路良率提升計畫】，計畫主持人，131050127，105/04/01~106/03/31 (500,000 元)
- F15. 聯勝光電股份有限公司，【聯勝光電發光二極體可靠度分析計畫】，計畫主持人，131040227-EQ，104/06/01~105/05/31 (300,000 元)
- F16. 奇景光電股份有限公司，【2015 奇景光電積體電路良率提升計畫】，計畫主持人，131040061，104/01/01~104/12/31 (500,000 元)
- F17. 新世紀光電股份有限公司，【2014 新世紀光電發光二極體故障分析 B 計畫】，計畫主持人，131030161-EQ，103/07/01~104/06/30 (600,000 元)
- F18. 聯勝光電股份有限公司，【2014 聯勝光電 LED 良率提升計畫】，計畫主持人，131030108-EQ，103/04/01~104/03/31 (300,000 元)
- F19. 奇景光電股份有限公司，【2014 奇景光電良率提升計畫】，計畫主持人，131030004，103/01/01~103/12/31 (500,000 元)
- F20. 新世紀光電股份有限公司，【2013 新世紀光電發光二極體晶粒故障分析 B 計畫】，計畫主持人，131020164，102/09/01~103/08/31 (300,000 元)
- F21. 奇景光電股份有限公司，【2012 奇景光電晶片良率提升計畫】，計畫主持人，131010529，101/11/01~102/10/31 (500,000 元)

G. 指導學生獲獎

- G1. 2023 全國創意行銷實務專題暨低碳生活企劃競賽(低碳生活創意企劃類)，指導學生王義雄、謝惠琦、葉峻瑋，題目【低碳人我的超人】，佳作獎
- G2. 萬潤 2023 創新創意競賽(大專組電機資訊類)，指導學生王義雄、謝惠琦、葉峻瑋，題目【智慧防毒面罩】，佳作獎
- G3. 2022 車用電子創新發明競賽(創新理念組)，指導學生葉峻瑋、曾煒翔、謝惠琦、柯皓嚴，題目【露營車用泡茶機】，佳作獎
- G4. 2022 International Symposium on Novel and Sustainable Technology (ISNST)，指導學生黃佳宏，題目【Study on β -Ga₂O₃ MSM Deep UV Photodetectors Deposited on Different Substrates by RF Magnetron Sputtering】，海報學生優秀論文獎(Poster Presentation Student Excellent Paper Award)
- G5. 2021 車用電子創新發明競賽(系統實現組)，指導學生彭彥凱、吳崧豪、江榮權，題目【基於環境檢測之高溫危害警報系統】，佳作獎
- G6. 2021 車用電子創新發明競賽(創新理念組)，指導學生黃佳宏、陳立忻、劉弘德、蔡祐典，題目【使用可撓式面板安裝於 A 柱改善行車視線】，佳作獎
- G7. 2020 International Symposium on Novel and Sustainable Technology (ISNST)，指導學生黃正耀，題目【The Study of Ga₂O₃/MgZnO Dual-Band Ultraviolet Photodetectors】，海報學生優秀論文獎(Poster Presentation Student Excellent Paper Award)

- G8. 2019 高雄 KIDE 國際發明暨設計展(大專院校組)，指導學生傅顯智、林宗翰、劉俊佳，題目【OPTICAL DETECTION DEVICE FOR GAS TRACE CONCENTRATION】，金牌獎
- G9. 2019 車用電子創新發明競賽(系統實現組)，指導學生黃莉蓉、王偉帆、劉俊佳、詹禮泰，題目【居家車庫即時光學空氣品質監測系統】，優等獎
- G10.2019 車用電子創新發明競賽(創新理念組)，指導學生劉泓德、陳立忻，題目【車載致冷水瓶】，佳作獎
- G11.2018 車用電子創新發明競賽(創新理念組)，指導學生詹禮泰、王偉帆、黃莉蓉，題目【安全駕車-紅外線觸碰式酒精偵測啟動器】，佳作獎
- G12.2018 車用電子創新發明競賽(創新理念組)，指導學生黃正耀、林宗翰，題目【頂叩叩-智慧安全帽】，佳作獎
- G13.2018 車用電子創新發明競賽(創新理念組)，指導學生許詠勛、高証揚、黃啟偉，題目【這個好-測好測滿】，佳作獎
- G14.2018 台灣國際創新發明暨設計競賽(發明類社會組)，指導學生黃正耀、林宗翰，題目【冬暖夏涼安全帽】，銅牌獎
- G15.2018 台灣國際創新發明暨設計競賽(發明類社會組)，指導學生許詠勛、高証揚及黃啟偉，題目【智慧型自動咖啡烘培機】，銅牌獎
- G16.2018 Optics & Photonics Taiwan, International Conference (OPTIC)，指導學生李珮瑀，題目【The Investigation of Optical Frequency Response of InGaN/GaN Blue LEDs with Electron Retarded Layer in Low Temperature Environment】，學生論文獎 (student paper award)
- G17.2017 車用電子創新發明競賽(創新理念組)，指導學生許詠勛、高証揚、黃啟偉，題目【車內氣體偵測器】，佳作獎
- G18.2017 車用電子創新發明競賽(創新理念組)，指導學生許詠勛、高証揚、黃啟偉，題目【行動咖啡烘培機】，佳作獎
- G19.2017 車用電子創新發明競賽(創新理念組)，指導學生葉育廷、吳信篁、傅顯智，題目【冬暖夏涼安全帽】，佳作獎
- G20.2017 車用電子創新發明競賽(創新理念組)，指導學生陳皇名、黃翊洛，題目【Life Fine Lock 隊】，佳作獎
- G21.2017 International Symposium on Novel and Sustainable Technology (ISNST)，指導學生許智翔，題目【Investigation of Nitride-Based Blue and Near Ultraviolet Flip Chip Light-Emitting Diodes】，海報論文獎第一名(First Prize of Poster Competition Award)
- G22.2016 車用電子創新發明競賽(創新理念組)，指導學生廖偉旭、李珮瑀，題目【進擊的車庫】，佳作獎
- G23.2016 車用電子創新發明競賽(創新理念組)，指導學生陳昆賢、葉育廷、傅顯智、吳信篁，題目【智慧馬桶-便便人生】，佳作獎
- G24.2016 車用電子創新發明競賽(創新理念組)，指導學生陳皇名、劉其偉、黃翊洛，題目【LI-FI 車鎖】，佳作獎
- G25.2016 第十一屆教育部技專院校數位訊號處理創思設計競賽(綠能與控制應用組)，指導學生王勛緯、郭家名、陳冠宇，題目【多功能獵取嬰兒車】，佳作獎
- G26.2015 第十一屆全國電子設計創意競賽(大專組綜合類)，指導學生黃聖翔、陳世勳、孫培鈞、高書賢、楊鎮毓、許智翔，題目【一扇門救你全家】，佳作獎
- G27.2014 全國 LED 創意設計競賽(應用產品設計組)，指導學生洪國慶、陳詠揚及徐鈺翔，題目【LED 浴廁濕滑警示器】，優選獎
- G28.2013 International Conference on Solid State Devices and Materials (SSDM 2013)，指導學生洪峻棋，題目【Performance Improvement of GaN Metal-Semiconductor-Metal Photodetectors with Sputtered AlN Nucleation Layer】，海外學生獎助金補助
- G29.2012 Optics & Photonics Taiwan, International Conference (OPTIC)，指導學生璩青陽，題目【Efficiency Improvement of Nitride-based LEDs with Different Last Barrier Thicknesses】，學生論文獎(student paper award)

H. 荣譽與獎勵

- H1. 科技部 109 學年度補助大專校院研究獎勵計畫之特殊優秀人才獎勵，特優研究獎
- H2. 科技部 108 學年度補助大專校院研究獎勵計畫之特殊優秀人才獎勵，特優研究獎
- H3. 科技部 107 學年度補助大專校院研究獎勵計畫之特殊優秀人才獎勵，績優研究獎
- H4. 科技部 106 學年度補助大專校院研究獎勵計畫之特殊優秀人才獎勵，績優研究獎
- H5. 科技部 105 學年度補助大專校院研究獎勵計畫之特殊優秀人才獎勵，績優研究獎